#### **Education**

### **University of Twente**

Oct 2014- present

PhD student at IMS, MESA+, University off Twente, The Netherlands

## **University of Twente**

Sep 2012- Aug 2014

Master of Nanotechnology (Major courses average grade: 7/10)

Main courses: Nanoscience, Advanced materials, Solid-state physics, Nanofabrication, Bionanotechnology, Characterization of nanostructure, Technology venturing.

#### **Guangxi Normal University**

Sep 2008-Jun 2012

Bachelor of Physics (Major courses average grade: 81/100)

Main courses: Mechanics, Thermodynamics, Electromagnetism, Optics, Quantum physics. Outstanding Graduates

#### Relevant Experience

# Master project, Dep. of ChemEng, University of Melbourne, Australia

Oct 2013-May 2014

**Topic:** Dissolution of interfacial microdroplets on hydrophobic surfaces

- Hydrophobic glass and silicon wafer preparation
- Using confocal microscopy to observe the dissolution of interfacial microdroplets on the hydrophobic surface.
- Data measurement and analyzed in Matlab.

# Lab course project, University of Twente, Enschede

Apr 2013-Jul 2013

Topic: Pulsed laser deposition of BiFeO<sub>3</sub> (BFO) on a multi-material substrate

- BFO separately deposited on STO-SRO and STO substrate by pulsed laser deposition (PLD).
- Sample characterization in Atomic force microscopy (AFM).

## Cleanroom course project, University of Twente, Enschede

Jan 2013-Mar 2013

• Silicon wafer patterned in three different methods: Electron Beam Lithography, Laser Interference Lithography and Focused Ion Beam Lithography.

## R&D department Océ-Technologies B.V. Venlo

May 2014- Aug 2014

**Topic:** Bubble entrapment during actuation of piezo acoustic print heads (experimental)

• Using the PAINt signal to observe the very early stage of bubble entrapment and what happens in short timescale (1-1000µs) after bubble entrapment

# **Skills Summary**

Language: Chinese (Mandarin), English, Cantonese, Dutch (learning).

Computer Skills: Microsoft office, originLab, Latex, Image Pro